



COPY OF PAPER  
ORIGINALLY FILED

COPY OF PAPERS  
ORIGINALLY FILED

2811

PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of: Satya et al.

Attorney Docket No.: KLA1P016F/P642

Application No.: 09/648,095

Examiner: P. Cao

Filed: August 25, 2000

Group: 2811

Title: CHEMICAL MECHANICAL POLISHING  
TEST STRUCTURES AND METHODS FOR  
INSPECTING THE SAME

#8  
Election  
FJONES  
7-30-02

**CERTIFICATE OF MAILING**  
I hereby certify that this correspondence is being deposited with the  
United States Postal Service as First Class Mail to: Commissioner for  
Patents, Washington, DC 20231 on July 12, 2002.

Signed: Natalie Morgan  
Natalie Morgan

**RESPONSE TO RESTRICTION REQUIREMENT B**

Commissioner for Patents  
Washington, DC 20231

Dear Sir:

In response to the Restriction Requirement dated 8 May 2002, Applicants hereby elect group A, claims 7 and 54-60, without traverse, to prosecute in the above-identified patent application.

If any fees are due in connection with the filing this Response to Restriction Requirement, the Commissioner is hereby authorized to charge such fees to Deposit Account 500388 (Order No. KLA1P016F).

Respectfully submitted,  
BEYER WEAVER & THOMAS, LLP

Mary R. Olynick  
Mary R. Olynick  
Registration No. 42,963

TECHNOLOGY CENTER 2800C

JUL 23 2002

RECEIVED

P.O. Box 778  
Berkeley, CA 94704-0778